

INFORMATION DISCLOSURE STATEMENT

(Use several sheets if necessary)

Applicant
Schueller, et al.Filing Date:
August 14, 2001

Group:







U.S. PATENT DOCUMENTS

Examiner's Initials	U.S. Patent No.	Applicant	Issue Date	Class	Subclass
am	4,260,725	Keogh et al.	April 7, 1981	526	
am	4,686,267	Ellis et al.	August 11, 1987	526	245
am	4,690,993	Falcetta et al.	September 1, 1987	526	242
am	4,711,943	Harvey	December 8, 1987	526	279
am	4,740,533	Su et al.	April 26, 1988	523	106
am	5,079,319	Mueller	January 7, 1992	526	238.23
am	5,143,854	Pirrung et al.	September 1, 1992	436	518
am	5,250,583	Kawaguchi et al.	October 5, 1993	523	107
am	5,331,067	Seidner et al.	July 19, 1994	525	479
am	5,387,663	McGee et al.	February 7, 1995	526	279
am	5,512,131	Kumar et al.	April 30, 1996	156	655.1
am	5,669,303	Maracas et al.	September 23, 1997	101	327
am	5,725,788	Maracas et al.	March 10, 1998	216	41
am	5,727,977	Maracas et al.	March 7, 1998	445	24
am	5,776,748	Singhvi et al.	July 7, 1998	435	180
am	5,817,242	Biebuyck et al.	October 6, 1998	216	41
am	5,900,160	Whitesides et al.	May 4, 1999	216	41
am	5,925,259	Biebuyck et al.	July 20, 1999	216	2
am	5,937,758	Maracas et al.	August 17, 1999	101	327
am	5,947,027	Burgin et al.	September 7, 1999	101	474
am	5,948,621	Turner et al.	September 7, 1999	435	6
am	5,951,881	Rogers et al.	September 14, 1999	216	41
am	5,965,237	Bruin et al.	October 12, 1999	428	156
am	5,976,826	Singhvi et al.	November 2, 1999	435	29
am	6,004,444	Aksay et al.	December 21, 1999	204	515
am	6,013,446	Maracas et al.	January 11, 2000	435	6
am	6,020,047	Everhart	February 1, 2000	428	209
am	6,027,595	Suleski	February 22, 2000	156	230



Form PTO-1449 (REV. 8-83)		U.S. Department of Commerce Patent and Trademark Office		Atty. Doc. No.: 2002907-0002		In re Application No. 09/929,736	
INFORMATION DISCLOSURE STATEMENT (Use several sheets if necessary)				Applicant Schueller, <i>et al.</i>			
				Filing Date: August 14, 2001		Group:	
6,033,202		Bao et al.		March 7, 2000		425	
6,039,897		Lochhead et al.		March 21, 2000		264	
6,060,121		Hidber et al.		May 9, 2000		427	
U.S. PATENT APPLICATIONS							
Examiner's Initials:	Serial Number:	Applicant:	Filing Date:	Group:	Art Unit:		
FOREIGN PATENT DOCUMENTS							
Examiner's Initials	Document No.	Country	Date	Translation			
				Yes	No		
OTHER DOCUMENTS							
Examiner's Initials	Citation (Including Author, Title, Date, Pertinent Pages, Etc.)						
	Amit, <i>et al.</i> , "Photosensitive Protecting Groups of Amino Sugars and Their Use in Glycoside Synthesis. 2-Nitrobenzyloxycarbonylamino and 6-Nitroveratryloxycarbonylamino Derivatives", <i>J. Org. Chem.</i> , 39 (2):192-196, 1974						
	Dulcey, <i>et al.</i> , "Photochemistry and Patterning of Self-Assembled Monolayer Films Containing Aromatic Hydrocarbon Functional Groups," <i>Langmuir</i> , 12 , 1638-1650, 1996.						
	Jackman, <i>et al.</i> , "Design and Fabrication of Topologically Complex, Three-Dimensional Microstructures," <i>Science</i> 280 :2089-2091, June 1998.						
	Jackman, <i>et al.</i> , "Electrochemistry and Soft Lithography: A Route to 3-D Microstructures," <i>Chemtech</i> 29 :18-30, May 1999.						
	Jackman, <i>et al.</i> , "Fabrication and Characterization of a Concentric Cylindrical Microtransformer," <i>IEEE Transactions on Magnetics</i> 33 (4):2501-2503, July 1997.						
	Jackman, <i>et al.</i> , "Fabrication of Submicrometer Features on Curved Substrates by Microcontact Printing," <i>Science</i> 269 :664-666, August 1995.						
	Jackman, <i>et al.</i> , "Fabrication of Three-Dimensional Microstructures by Electrochemically Welding Structures Formed by Microcontact Printing on Planar and Curved Substrates," <i>Journal of Microelectromechanical Systems</i> 7 (2):261-266, June 1998.						
	Jackman, <i>et al.</i> , "Three-Dimensional Metallic Microstructures Fabricated by Soft Lithography and Microelectrodeposition," <i>Langmuir</i> 15 (3):826-836, January 1999.						
	Nakamura, <i>et al.</i> , "Room-Temperature Continuous Wave Operation of InGaN Multi-Quantum-Well-Structure Laser Diodes with a Long Lifetime" <i>Appl. Phys. Lett.</i> , 70 (7):868-870, 1997.						
	Patchornik, "Photosensitive Protecting Groups" <i>J. Am. Chem. Soc.</i> , 92 (21):6333-6335, 1970						



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Form PTO-1449 (REV. 8-83)	U.S. Department of Commerce Patent and Trademark Office	Atty. Docket: 2002907-0002	In re Application No. 09/929,736
INFORMATION DISCLOSURE STATEMENT (Use several sheets if necessary)		Applicant Schueller, <i>et al.</i>	
		Filing Date: August 14, 2001	Group:
	Rogers, <i>et al.</i> , "Constructing Single- and Multiple-Helical Microcoils and Characterizing Their Performance as Components of Microinductors and Microelectromagnets," <i>Journal of Microelectromechanical Systems</i> 6(3):184-192, September 1997.		
	Rogers, <i>et al.</i> , "Microcontact Printing and Electroplating on Curved Substrates: Production of Free-Standing Three-Dimensional Metallic Microstructures," <i>Advanced Materials</i> 9(6):475-477, 1997.		
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	Rogers, <i>et al.</i> , "Using Microcontact Printing to Generate Amplitude Photomasks on the Surfaces of Optical Fibers: A Method for Producing In-Fiber Gratings," <i>Appl. Phys. Lett.</i> 70(1):7-9, January 1997.		
	Terrill, <i>et al.</i> , "Dynamic Monolayer Gradients: Active Spatiotemporal Control of Alkanethiol Coatings on Thin Gold Films," <i>J. Am. Chem. Soc.</i> 122(5):988-989, February 2000.		
	Xia, <i>et al.</i> , "Soft Lithography," <i>Angewandte Chemie International Edition</i> 37(5):550-575, March 1998.		

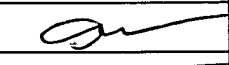

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Form PTO-1449 (REV. 8-83)	U.S. Department of Commerce Patent and Trademark Office	Atty. Docket: 2002907-0002	In re Application No. 09/929,736
SUPPLEMENTAL INFORMATION DISCLOSURE STATEMENT <i>(Use several sheets if necessary)</i>		Applicant: Schueller et al.	
		Filing Date: August 14, 2001	Group: 1651

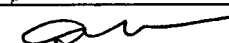
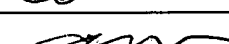
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	2,957,410	Traphagen	October 25, 1960	101	110
	5,435,245	Salisbury et al.	July 25, 1995	101	328


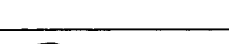
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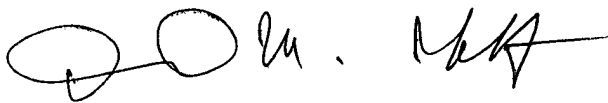
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	EP 1 001 311	Europe	17 May 2000		
	EP 0 313 172	Europe	26 April 1989		
	DE 70607	Germany	7 February 1893		X
	WO 96/29629	PCT	26 September 1996		

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	"Lithographie mit "Lichtstempeln" Technische Rundschau, Hallwag Verlag. Bern, Ch., Vol. 90, No. 19, Page 20, 9 October, 1998.
	International Search Report issued for corresponding PCT application PCT/US01/25429.

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